## IN THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application. An identifier indicating the status of each claim is provided.

## Listing of Claims:

## 1-4. (Canceled)

(Currently Amended) A solid-state image pickup device comprising:

 a photosensor portion having first and second opposite sides, the photosensor portion
 being provided on the surface of a substrate to convert light incident on said first side into
 electric charges;

a transfer portion formed on the surface of said substrate to transfer said electric charges read out from said photosensor portion; and

an overflow barrier formed within said substrate and opposite the second side of said photosensor portion to discharge unnecessary electric charges of said electric charges,

wherein potential under said transfer portion is formed smaller than that formed under said photosensor portion along the depth direction of said substrate in a range from the minimum potential position to said overflow barrier,

wherein said transfer portion has one or a plurality of impurity regions formed at its second side.

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wherein one or a plurality of second impurity regions formed under said photosensor

portion are formed with depths different from that of said impurity region, and A solid-state

image pickup device according to claim 4,

wherein said impurity region is arranged in four layers along the depth direction of said

substrate and said second impurity region is arranged in seven layers along the depth direction of

said substrate.

6. (Currently Amended) A solid-state image pickup device according to claim 5elaim 4,

wherein said impurity region is a P type impurity region and said second impurity region is an N

type impurity region.

7-9. (Canceled)

10. (Currently Amended) A solid-state image pickup device according to elaim 1claim 5,

wherein said substrate is composed of a first substrate and a second substrate formed on

an upper layer of said first substrate and which is higher in resistance than said first substrate,

said first substrate being of a first conductivity type and said second substrate being of said first

conductivity type or a second conductivity type.

11. (Canceled)

12-17. (Withdrawn)

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18. (New) A solid-state image pickup device comprising:

a photosensor portion having first and second opposite sides, the photosensor portion being provided on the surface of a substrate to convert light incident on said first side into electric charges;

a transfer portion formed on the surface of said substrate to transfer said electric charges read out from said photosensor portion; and

an overflow barrier formed within said substrate and opposite the second side of said photosensor portion to discharge unnecessary electric charges of said electric charges,

wherein potential under said transfer portion is formed smaller than that formed under said photosensor portion along the depth direction of said substrate in a range from the minimum potential position to said overflow barrier,

wherein said transfer portion has one or a plurality of impurity regions formed at its second side.

wherein one or a plurality of second impurity regions formed under said photosensor portion are formed with depths different from that of said impurity region, and

wherein said impurity region is arranged in more than three layers along the depth direction of said substrate and said second impurity region is arranged in more than three layers along the depth direction of said substrate.

19. (New) A solid-state image pickup device according to claim 18, wherein said impurity region is a P type impurity region and said second impurity region is an N type impurity region.

20. (New) A solid-state image pickup device according to claim 18,

wherein said substrate is composed of a first substrate and a second substrate formed on an upper layer of said first substrate and which is higher in resistance than said first substrate, said first substrate being of a first conductivity type and said second substrate being of said first conductivity type or a second conductivity type.